

April 12, 2006

UltraSource thin film fabrication in accordance with RoHs Initiatives

UltraSource is a premier supplier of custom thin film manufactured devices to electronic and industrial markets and is fully committed to supporting Restriction of Hazardous Substances (RoHS) directive 2002/95/E. UltraSource, Inc. hereby declares and certifies that the thin film fabrication of the following substrates is in accordance with RoHS directives.

- Alumina (Aluminum Oxide)
- Quartz/Fused Silica
- Aluminum Nitride
- Beryllium Oxide
- Glass
- Sapphire
- Silicon

UltraSource hereby states that none of the following list of banned substances is present in any part of or used in the thin film fabrication of the previously listed substrates.*

1. Lead (Pb) 0.1%
2. Mercury (Hg) 0.1%
3. Cadmium (Cd) 0.01%
4. Hexavalent Chromium (Cr +6) 0.1%
5. Polybrominated Biphenyls (PBB) 0.1%
6. Polybrominated Biphenyl Ethers (PBDE) 0.1%

*A maximum concentration of 0.1% by weight in homogenous materials for lead mercury, hexavalent chromium, polybrominated biphenyls (PBB) and polybrominated biphenyl ethers (PBDE) and of 0.01% by weight in homogenous materials for cadmium shall be tolerated. Lead in glass and ceramics is exempt per No. 5 of the RoHS annex.



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